## BEAM INTENSITY \& POSITION MONITORS




# The photons you lose at least count 

## Alibava Systems offers Silicon Transmission Photodiodes with very low absorption < 20\%

( $4,5 \mathrm{keV}$ ) and very high efficiency.

Alibava Beam Intensity \& Position Monitors are small, easy to install and passive photodiode circuit for X-ray beam diagnostic applications. This solution provides actual X-ray beam intensity and position data through direct measurement. Furthermore, its transmission properties allow the online monitoring of the most critical beam parameter simultaneously with the data acquisition during an experiment.

This valuable characteristic is achieved through its innovative thin detector with a very high X-ray transmission, good responsivity uniformity, stable, low absorption, and uniform radiation stability.

This Beam Intensity and Position Monitors were developed in collaboration with ALBA Synchrotron. Thanks to its unique characteristics Alibava Beam Intensity and Position Monitors are especially useful not only for beamlines characterization in synchrotrons but also for quality control of monochromatic X-ray machinery.

## 02 Features \& Electronic Characterization

- P on N silicon detector
- Size: $4.4 \times 4.4 \mathrm{~mm}^{2}$
- Thickness: 3 / 5 / $10 \mu \mathrm{~m}$
- No external voltage needed
- Easily mounted in the experiment
- The beam intensity is measured by the output current
- Depletion layer thickness (bias = 0): 2.6 / 3.7 / $7 \mu \mathrm{~m}$



## 02 <br> Features \& Electronic Characterization

Electronic Characterization

| Model No. | Active area ( $\mathrm{mm}^{2}$ ) | Breakdown Voltage ${ }^{(1)}$ (V) | Dark Current ${ }^{(2)}$ <br> (pA) | Capacitance C(2) (nF) | Shunt Resistanc e (M) | Sensitivity S(3) (A/W) | Max Storage $\mathbf{T e}$ ( $\left.{ }^{\circ} \mathrm{C}\right)$ |
| :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: |
| $\begin{gathered} \text { Beam Intensity } \\ \text { AS04-104X03 } \\ 4.4 \times 4.4 \mathrm{~mm}^{2} \end{gathered}$ | 19.36 | 10 | 0.13 | 0,410 | 420 | 0,011 | 80 |
| Intensity and Position AS04-404X03 $4.4 \times 4.4 \mathrm{~mm}^{2}$ | 19.36 | 10 | 0.13 | 0,410 | 420 | 0,011 | 80 |
| Beam Intensity AS04-104X05 $4.4 \times 4.4 \mathrm{~mm}^{2}$ | 19.36 | 10 | 0.13 | 0,246 | 420 | 0,018 | 80 |
| Intensity and Position AS04-404X05 $4.4 \times 4.4 \mathrm{~mm}^{2}$ | 19.36 | 10 | 0.13 | 0,246 | 420 | 0,018 | 80 |
| Beam Intensity AS04-104X10 $4.4 \times 4.4 \mathrm{~mm}^{2}$ | 19.36 | 10 | 0.13 | 0,123 | 420 | 0.035 | 80 |
| Intensity and Position AS04-404X10 $4.4 \times 4.4 \mathrm{~mm}^{2}$ | 19.36 | 10 | 0.13 | 0,123 | 420 | 0.035 | 80 |

X: Diferent Product configurations

## 03 Transmission Properties

- Wide energy range
- Transmission level above $80 \%$ at 4.5 keV and $94 \%$ at 12 keV
- Responsivity uniformity better than $5 \%$ inside the active area



## 03 Transmission Properties Graphic



## 04 Diode Detail \& PCB

Diode Detail


## Printed Circuit Board*


32.10 mm

Single and four quadrants designs to perform intensity and position measurements

## 01 Different Configurations

Alibava Beam Intensity \& Position Monitors can be provided in four different configurations:

## 1. Standard

The diode is installed on a compact light-shielded housing equipped with fixation holes and Lemo connectors.

- Opaque housing
- Individual coaxial Lemo connectors
- Dimensions: $41 \times 68 \times 12.5 \mathrm{~mm}$



## 02 Difierent Configurations

## 2. Vacuum

The diode is installed on a very compact high vacuum compatible chamber with KF 40 terminations.

- 36 mm compact chamber
- KF 40 terminations
- Individual coaxial Lemo connectors



## 3. Naked

The diode is provided a high vacuum compatible PCB which makes the system ideal for custom integration.

For Dimensions:

## See Printed Circuit Board at page: Diode Detail \& PCB.



## 03 Different Configurations

## 4. Ultra High Vacuum

This UHV X-Ray Beam Intensity and Position Monitors have been especially developed for UHV environments based on UHV compatible materials with very low outgoing rates. Each device is supplied with an outgassing test report.

These features make the UHV Beam Intensity $\mathbb{\&}$ Position Monitors ideal to be installed on the optical elements of the beam line as can be monochromators and mirrors as well as in high demanding vacuum experimental environments.

For Dimensions:
See Printed Circuit Board at page: Diode Detail \& PCB.

## Users of Beam Intensity \& Position Monitors

## 05 Sirius Synchrotron

Alibava Systems have supplied the Brazilian Center for Research in Energy and Materials (CNPEM) with six UHV Beam Intensity for the Sirius Synchrotron de Brasil.

Sirius Synchrotron will use these diodes for beam monitoring and conditioning at the optical part of beamlines.


## 06 Elettra Synchrotron Trieste

Alibava Systems have supplied Elettra Synchrotron Trieste with a Vacuum Beam Intensity and Position Monitor.

Elettra Synchrotron uses Alibava Beam Position Monitors together with Elettra Fast Picoammeter to perform beam optimization and Beam Intensity Monitoring.


## Elettra Sincrotrone Trieste



## Picoammeter

Especially suited for applications
where multi-channel fast
acquisition is a concern
I.E. Feedback

Systems

## 01 Picoammeter

Alibava Systems can also provide fast acquisitions Picoammeter specially suitable for beam intensity and position measurement.

## Applications

- Ultra-low current measurements.
- Beam position monitoring.
- Si and Diamond detectors readout.
- Ion chamber readout.


This product is sold under license of Elettra Sincrotrone Trieste (Italy).

## Want To Learn

More?

## 06 Contact Us

For more information about the Beam Intensity \& Position Monitors please contact us:


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